## **EXPRESS MAIL NO. EV371410951US**

**PATENT** 

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Serial No:

**EXPRESS MAIL NO. EV371410951US** 

Filing Date:

Filed herewith

Applicant:

Frank M. Cerio, Jr. et al.

Title:

IONIZED PHYSICAL VAPOR DEPOSITION (iPVD) PROCESS

Atty Docket:

TAZ-259

MS Patent Application Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

## INFORMATION DISCLOSURE STATEMENT

In accordance with the duty of candor and good faith imposed by 37 CFR §1.56 and means of complying therewith according to 37 CFR §§1.97 and 1.98, the references listed on the attached PTO-1449 are called to the attention of the United States Patent and Trademark Office in connection with the above-identified patent application.

This application was filed after June 30, 2003, and therefore, no copies are enclosed of the U.S. Patents or Published applications cited as references herein.

No admission is made that the cited art represents the prior art or that the cited art is the most material art. Applicant submits that none of the cited references alone or in combination disclose or render obvious the subject matter in the present invention. The Examiner is urged to consider the cited references and to make an independent decision with respect to their materiality.

Respectfully submitted,

WOOD, HERRON & EVANS

C. Richard Eby, Reg. No. 25,854

2700 Carew Tower Cincinnati, Ohio 45202-2917

PH: (513) 241-2324 FX: (513) 241-6234

Sheet 1 (A) of 1

										MENT OF COMMERCE TRADEMARK OFFICE		ATTY. DOCKET NO. TAZ-259			SERIAL NO. EXPRESS MAIL NO. EV371410951US	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT												APPLICANT Cerio, Jr., et al.				
(Use several sheets if necessary) (37 CFR 1.98(b))											FILING DATE Filed Herewith			GROUP		
	-								U.S. 1	PATENT	DOCUMENTS					
EXAMINER INITIAL		PATENT NUMBER DATE									PATENTEE CLASS SUE			SUBC	FILING DATE ICLASS IF APPROPRIATE	
	A.A	6	6 2 8 7 4 3 5 09/2001 Drewery				y et al.									
	A.B											•				
	A.C															
	A.D															
	A.E															
- 12	A.F															
	A.G															
	A.H												_			
	A.I															
	A.J															
	A.K															
FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS																
		DOCUMENT NUMBER						Р	UBLICATION DATE	F	COUNTRY OF PATENT OFFIC		CLASS	SUBCL	ASS	TRANSLATION (YES/NO)
	A.L														*****	
	A.M															
	A.N															
	A.O															
	A.P															
	A.Q															<u>.</u>
					_0	THE	R	oci	JMENTS (Incl	uding Aut	hor, Title, Date	, Place o	f Publication	)		
	A.R	Yasar et al., Patent Application Publication No. US 2003/O034244 A1, Pub. Date February 20, 2003														
	A.S															
	A.T									-						
EXAMINER											DATE CONSIDERED					
EXAMINER: In Include a copy										mance. D	raw line throug	h citation	only if not in	n conform	ance <u>an</u>	d not considered.

**▶**...}